

ABSTRACT OF THE DISCLOSURE

A thin-film semiconductor device used for a display region and peripheral circuit region and a method of manufacturing the same are provided: A

- 5 method of manufacturing a display device includes the step of preparing a member having, on a separation layer, a semiconductor film having a first region with a switching element and a second region with a peripheral circuit, the step of forming an image
- 10 display portion on the first region, and the separation step of separating the first and second regions from the member.

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